

DATA SHEET

BF998; BF998R Silicon N-channel dual-gate MOS-FETs

Product specification
Supersedes data of April 1991
File under Discrete Semiconductors, SC07

1996 Aug 01

Silicon N-channel dual-gate MOS-FETs

BF998; BF998R

FEATURES

- Short channel transistor with high forward transfer admittance to input capacitance ratio
- Low noise gain controlled amplifier up to 1 GHz.

APPLICATIONS

- VHF and UHF applications with 12 V supply voltage, such as television tuners and professional communications equipment.

DESCRIPTION

Depletion type field effect transistor in a plastic microminiature SOT143 or SOT143R package with source and substrate interconnected. The transistors are protected against excessive input voltage surges by integrated back-to-back diodes between gates and source.

CAUTION

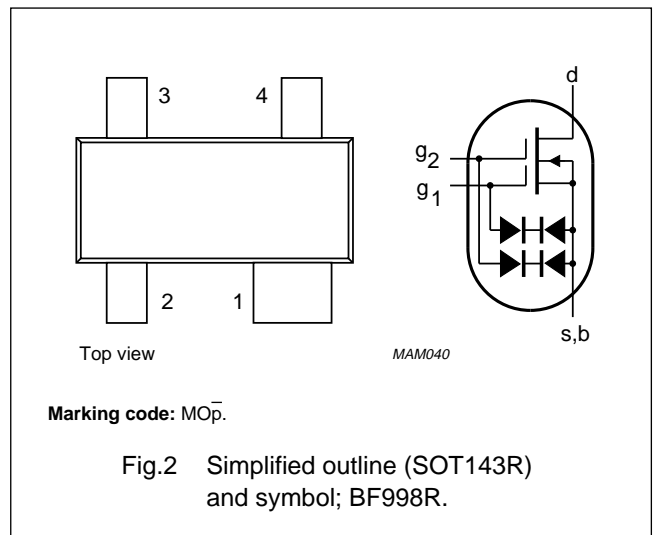
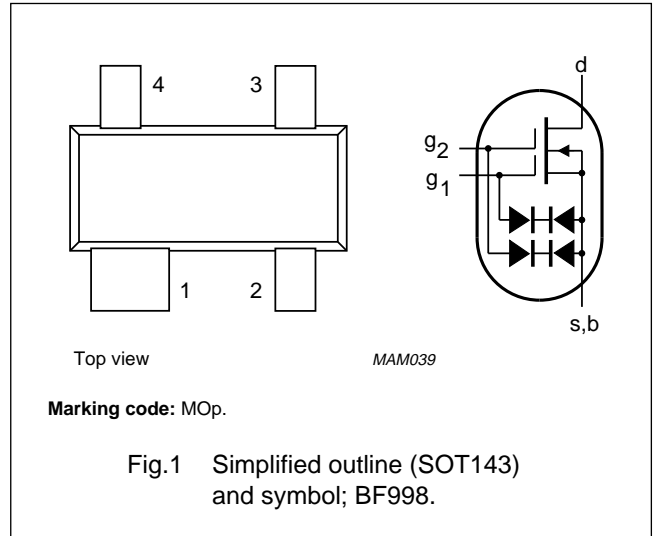
The device is supplied in an antistatic package. The gate-source input must be protected against static discharge during transport or handling.

PINNING

| PIN | SYMBOL | DESCRIPTION |
|-----|----------------|-------------|
| 1 | s, b | source |
| 2 | d | drain |
| 3 | g ₂ | gate 2 |
| 4 | g ₁ | gate 1 |

QUICK REFERENCE DATA

| SYMBOL | PARAMETER | CONDITIONS | TYP. | MAX. | UNIT |
|--------------------|--------------------------------|-------------|------|------|------|
| V _{DS} | drain-source voltage | | – | 12 | V |
| I _D | drain current | | – | 30 | mA |
| P _{tot} | total power dissipation | | – | 200 | mW |
| y _{fs} | forward transfer admittance | | 24 | – | mS |
| C _{ig1-s} | input capacitance at gate 1 | | 2.1 | – | pF |
| C _{rs} | reverse transfer capacitance | f = 1 MHz | 25 | – | fF |
| F | noise figure | f = 800 MHz | 1 | – | dB |
| T _j | operating junction temperature | | – | 150 | °C |



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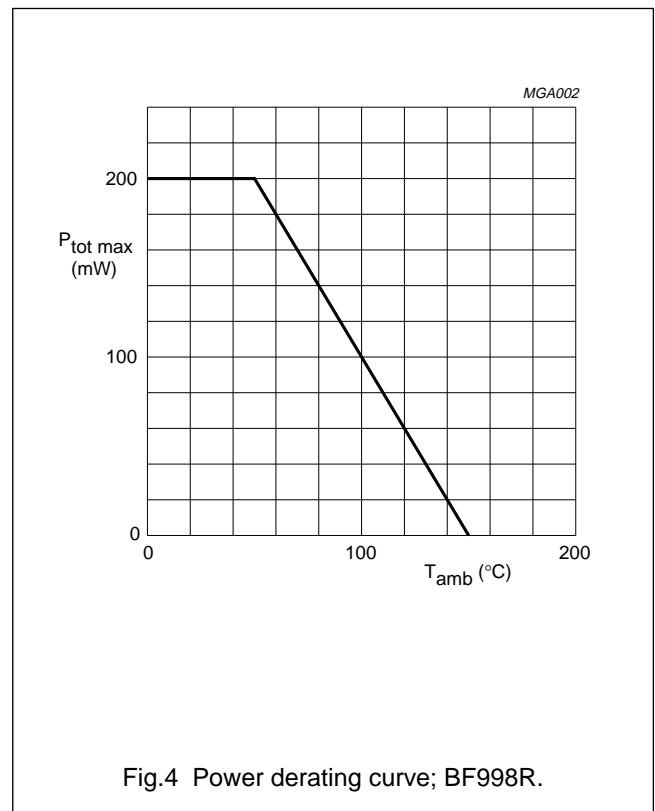
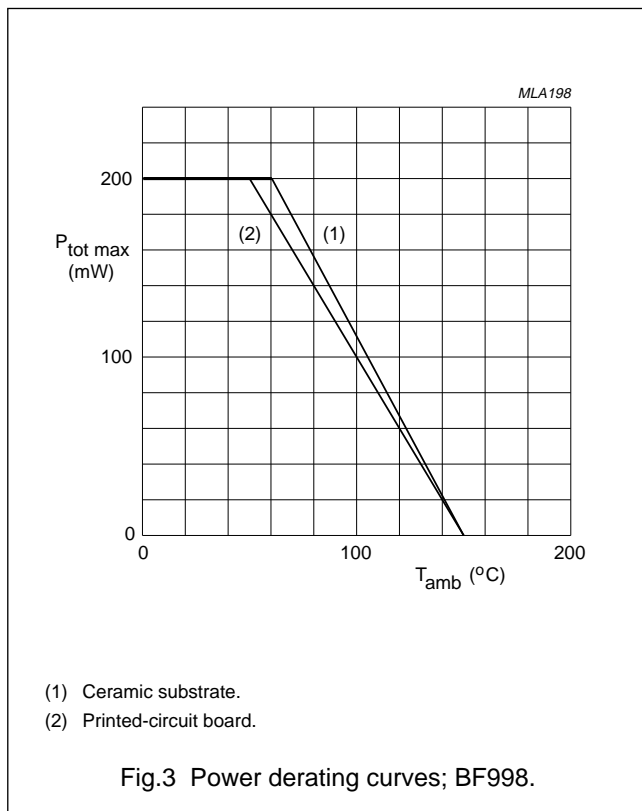
LIMITING VALUES

In accordance with the Absolute Maximum Rating System (IEC 134).

| SYMBOL | PARAMETER | CONDITIONS | MIN. | MAX. | UNIT |
|--------------|---------------------------------|--|------|------|------------------|
| V_{DS} | drain-source voltage | | – | 12 | V |
| I_D | drain current | | – | 30 | mA |
| $\pm I_{G1}$ | gate 1 current | | – | 10 | mA |
| $\pm I_{G2}$ | gate 2 current | | – | 10 | mA |
| P_{tot} | total power dissipation; BF998 | up to $T_{amb} = 60\text{ }^\circ\text{C}$; see Fig.3; note 1 | – | 200 | mW |
| | | up to $T_{amb} = 50\text{ }^\circ\text{C}$; see Fig.3; note 2 | – | 200 | mW |
| P_{tot} | total power dissipation; BF998R | up to $T_{amb} = 50\text{ }^\circ\text{C}$; see Fig.4; note 1 | – | 200 | mW |
| T_{stg} | storage temperature | | –65 | +150 | $^\circ\text{C}$ |
| T_j | operating junction temperature | | – | 150 | $^\circ\text{C}$ |

Notes

1. Device mounted on a ceramic substrate, 8 mm × 10 mm × 0.7 mm.
2. Device mounted on a printed-circuit board.



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THERMAL CHARACTERISTICS

| SYMBOL | PARAMETER | CONDITIONS | VALUE | UNIT |
|---------------|---|------------|-------|------|
| $R_{th\ j-a}$ | thermal resistance from junction to ambient in free air; BF998 | note 1 | 460 | K/W |
| | | note 2 | 500 | K/W |
| $R_{th\ j-a}$ | thermal resistance from junction to ambient in free air; BF998R | note 1 | 500 | K/W |

Notes

1. Device mounted on a ceramic substrate, 8 mm × 10 mm × 0.7 mm.
2. Device mounted on a printed-circuit board.

STATIC CHARACTERISTICS

$T_j = 25\text{ }^\circ\text{C}$; unless otherwise specified.

| SYMBOL | PARAMETER | CONDITIONS | MIN. | MAX. | UNIT |
|---------------------|---------------------------------|---|------|------|------|
| $\pm V_{(BR)G1-SS}$ | gate 1-source breakdown voltage | $V_{G2-S} = V_{DS} = 0$; $I_{G1-SS} = \pm 10\text{ mA}$ | 6 | 20 | V |
| $\pm V_{(BR)G2-SS}$ | gate 2-source breakdown voltage | $V_{G1-S} = V_{DS} = 0$; $I_{G2-SS} = \pm 10\text{ mA}$ | 6 | 20 | V |
| $-V_{(P)G1-S}$ | gate 1-source cut-off voltage | $V_{G2-S} = 4\text{ V}$; $V_{DS} = 8\text{ V}$; $I_D = 20\text{ }\mu\text{A}$ | – | 2.0 | V |
| $-V_{(P)G2-S}$ | gate 2-source cut-off voltage | $V_{G1-S} = 0$; $V_{DS} = 8\text{ V}$; $I_D = 20\text{ }\mu\text{A}$ | – | 1.5 | V |
| I_{DSS} | drain-source current | $V_{G2-S} = 4\text{ V}$; $V_{DS} = 8\text{ V}$; $V_{G1-S} = 0$; note 1 | 2 | 18 | mA |
| $\pm I_{G1-SS}$ | gate 1 cut-off current | $V_{G2-S} = V_{DS} = 0$; $V_{G1-S} = \pm 5\text{ V}$ | – | 50 | nA |
| $\pm I_{G2-SS}$ | gate 2 cut-off current | $V_{G1-S} = V_{DS} = 0$; $V_{G2-S} = \pm 5\text{ V}$ | – | 50 | nA |

Note

1. Measured under pulse condition.

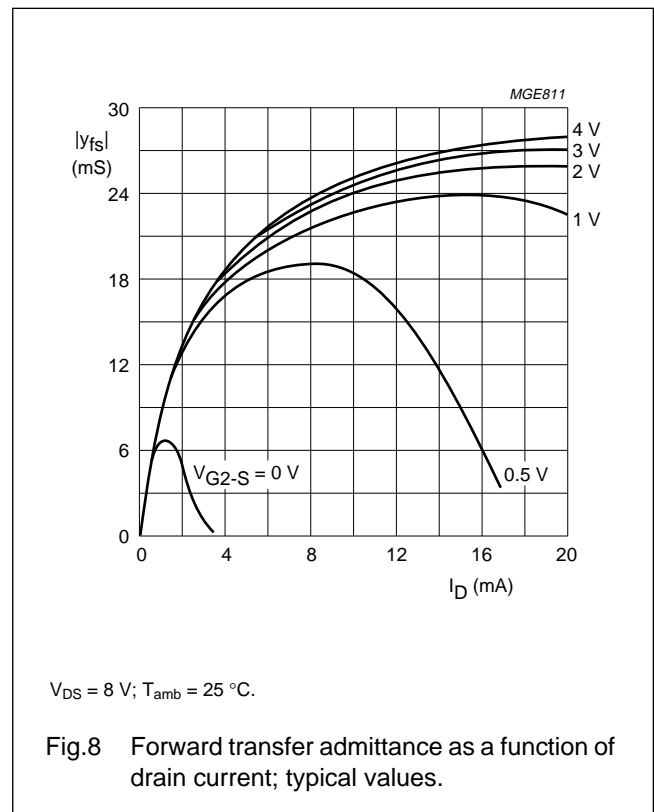
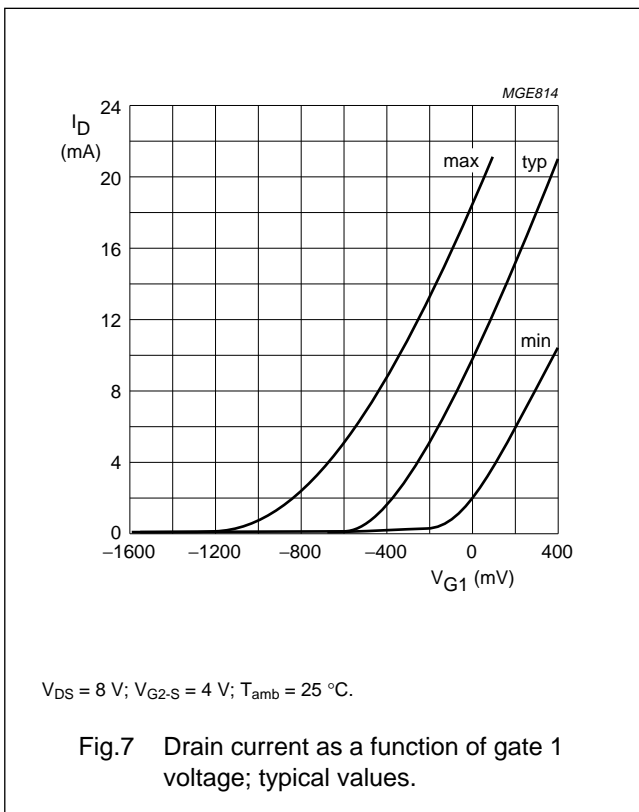
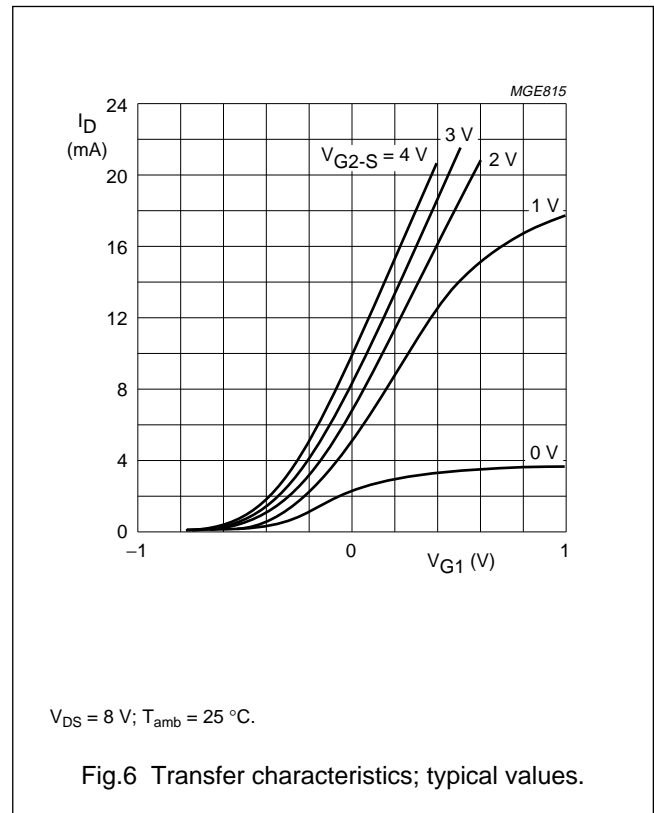
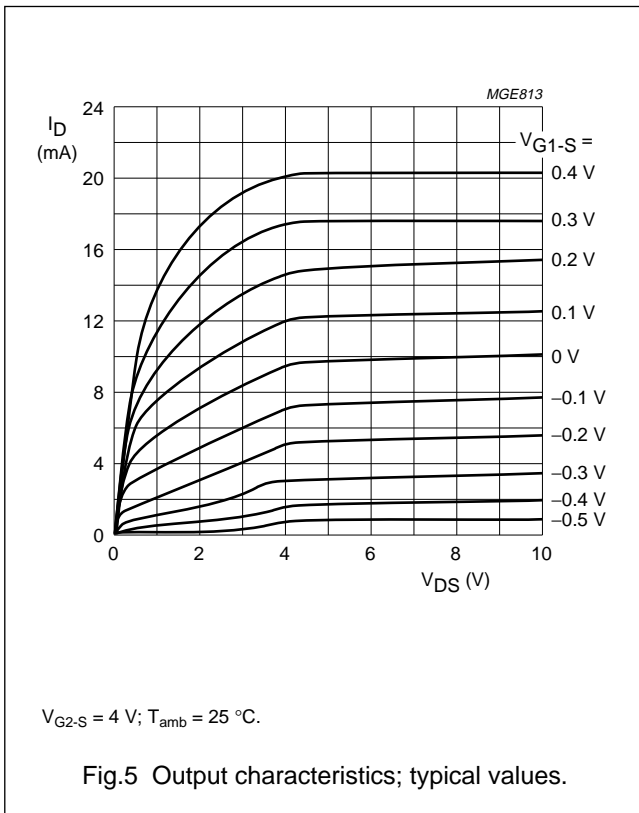
DYNAMIC CHARACTERISTICS

Common source; $T_{amb} = 25\text{ }^\circ\text{C}$; $V_{DS} = 8\text{ V}$; $V_{G2-S} = 4\text{ V}$; $I_D = 10\text{ mA}$.

| SYMBOL | PARAMETER | CONDITIONS | MIN. | TYP. | MAX. | UNIT |
|-------------|------------------------------|---|------|------|------|------|
| $ y_{fs} $ | forward transfer admittance | $f = 1\text{ kHz}$ | 21 | 24 | – | mS |
| C_{ig1-s} | input capacitance at gate 1 | $f = 1\text{ MHz}$ | – | 2.1 | 2.5 | pF |
| C_{ig2-s} | input capacitance at gate 2 | $f = 1\text{ MHz}$ | – | 1.2 | – | pF |
| C_{os} | output capacitance | $f = 1\text{ MHz}$ | – | 1.05 | – | pF |
| C_{rs} | reverse transfer capacitance | $f = 1\text{ MHz}$ | – | 25 | – | fF |
| F | noise figure | $f = 200\text{ MHz}$; $G_S = 2\text{ mS}$; $B_S = B_{Sopt}$ | – | 0.6 | – | dB |
| | | $f = 800\text{ MHz}$; $G_S = 3.3\text{ mS}$; $B_S = B_{Sopt}$ | – | 1.0 | – | dB |

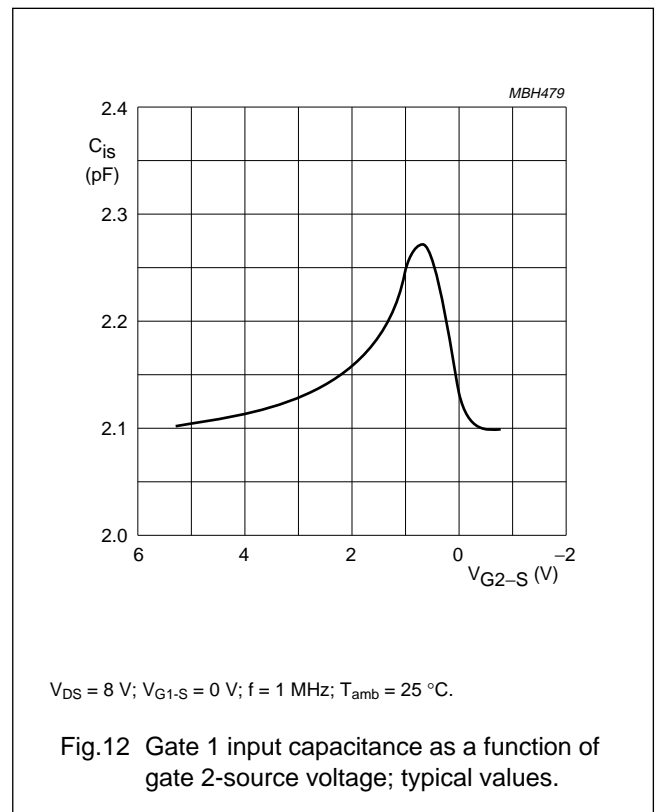
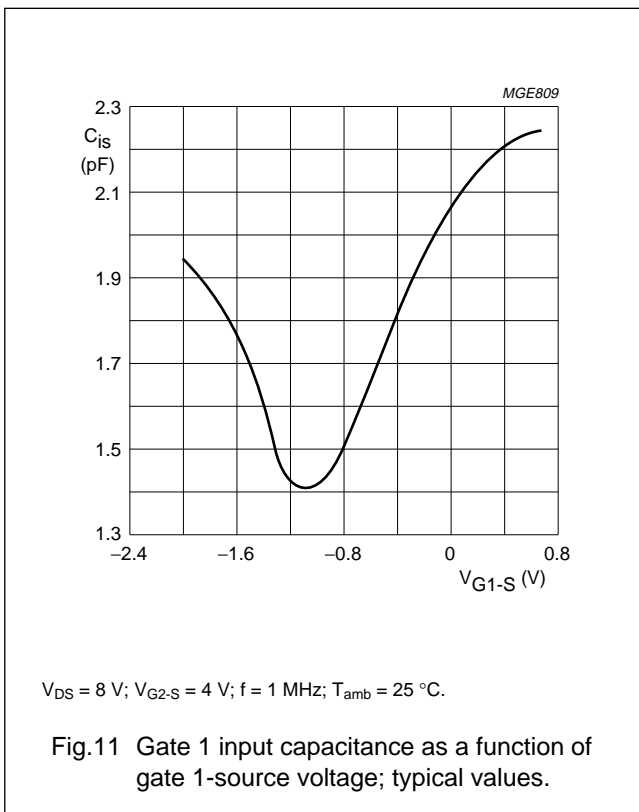
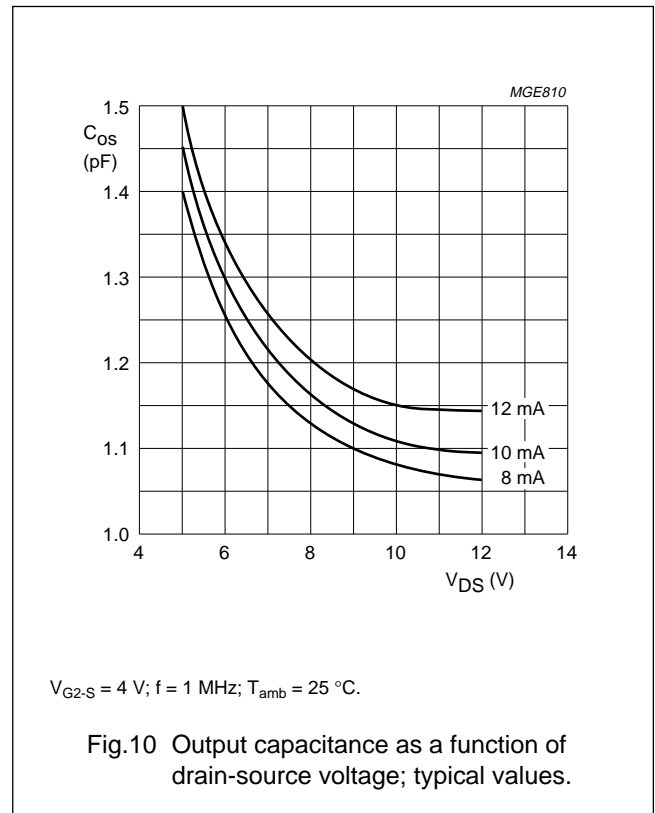
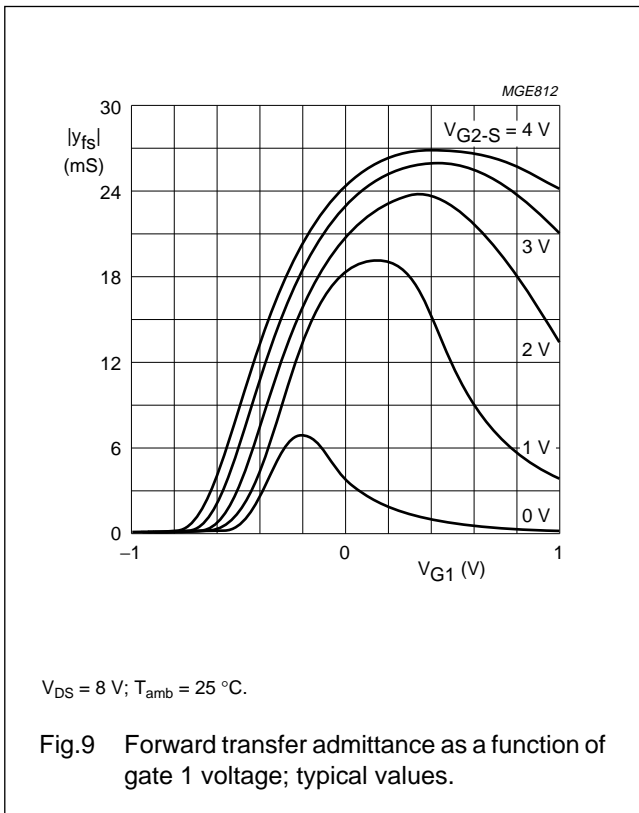
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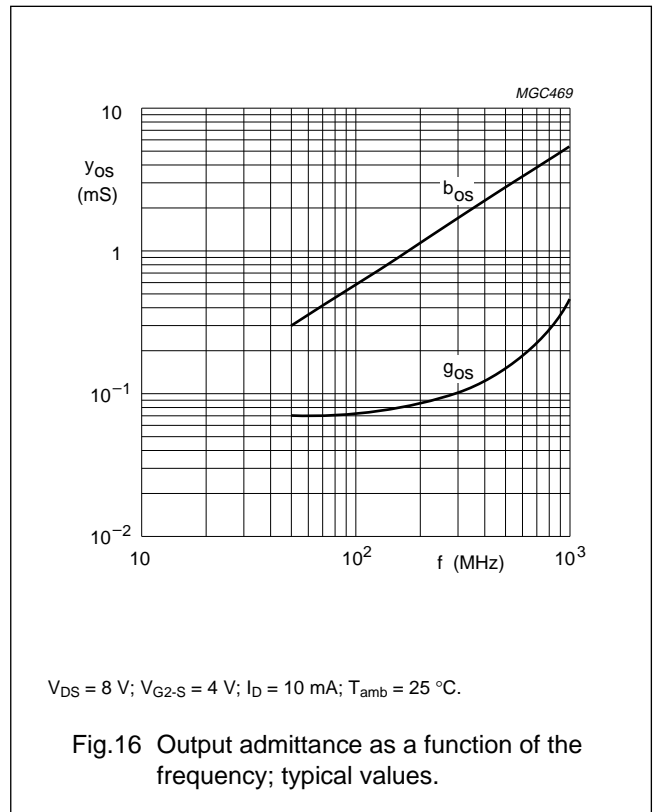
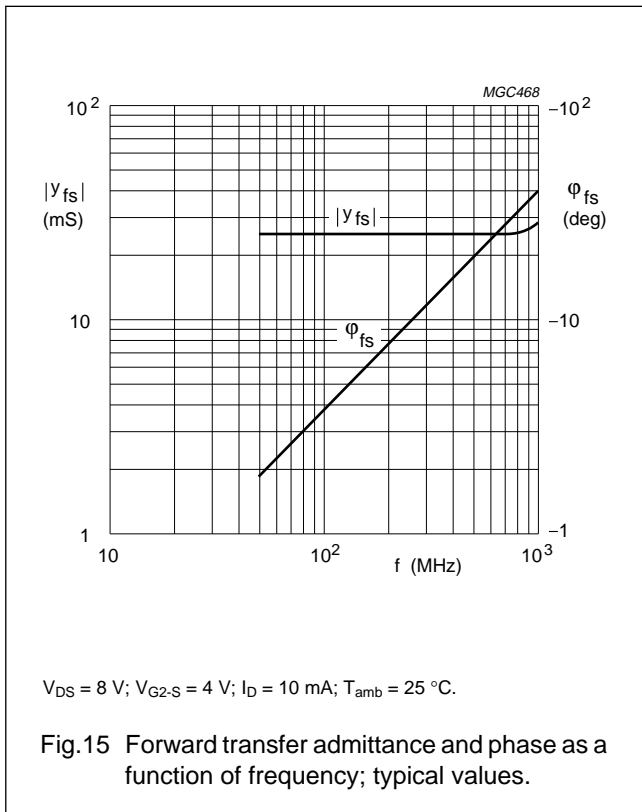
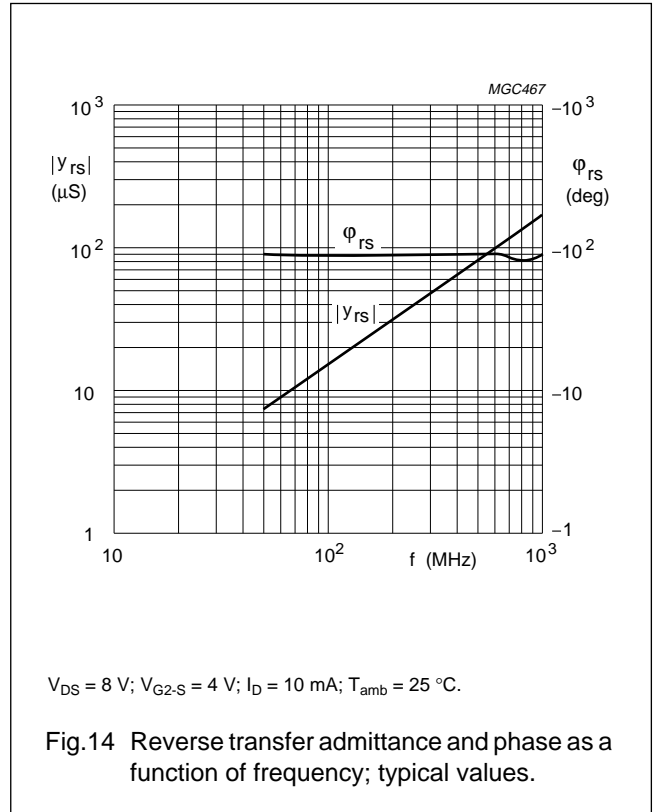
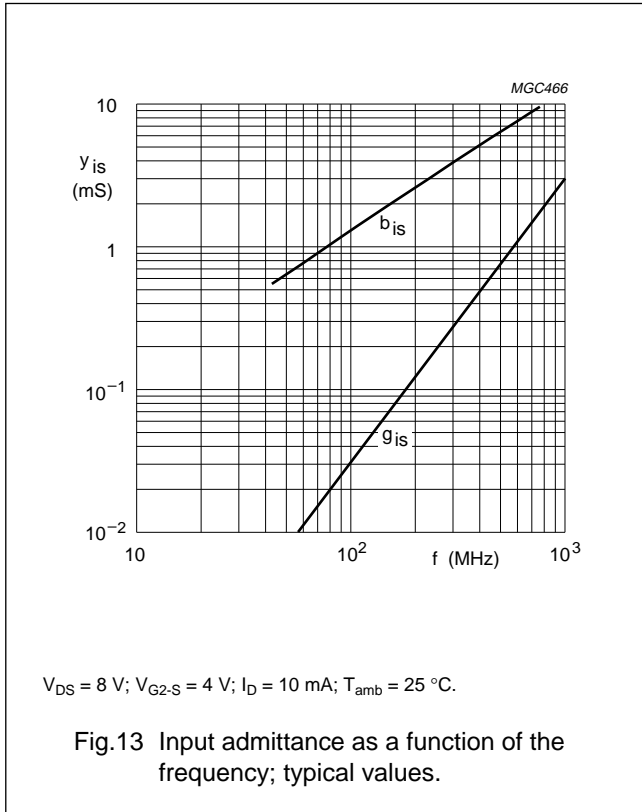
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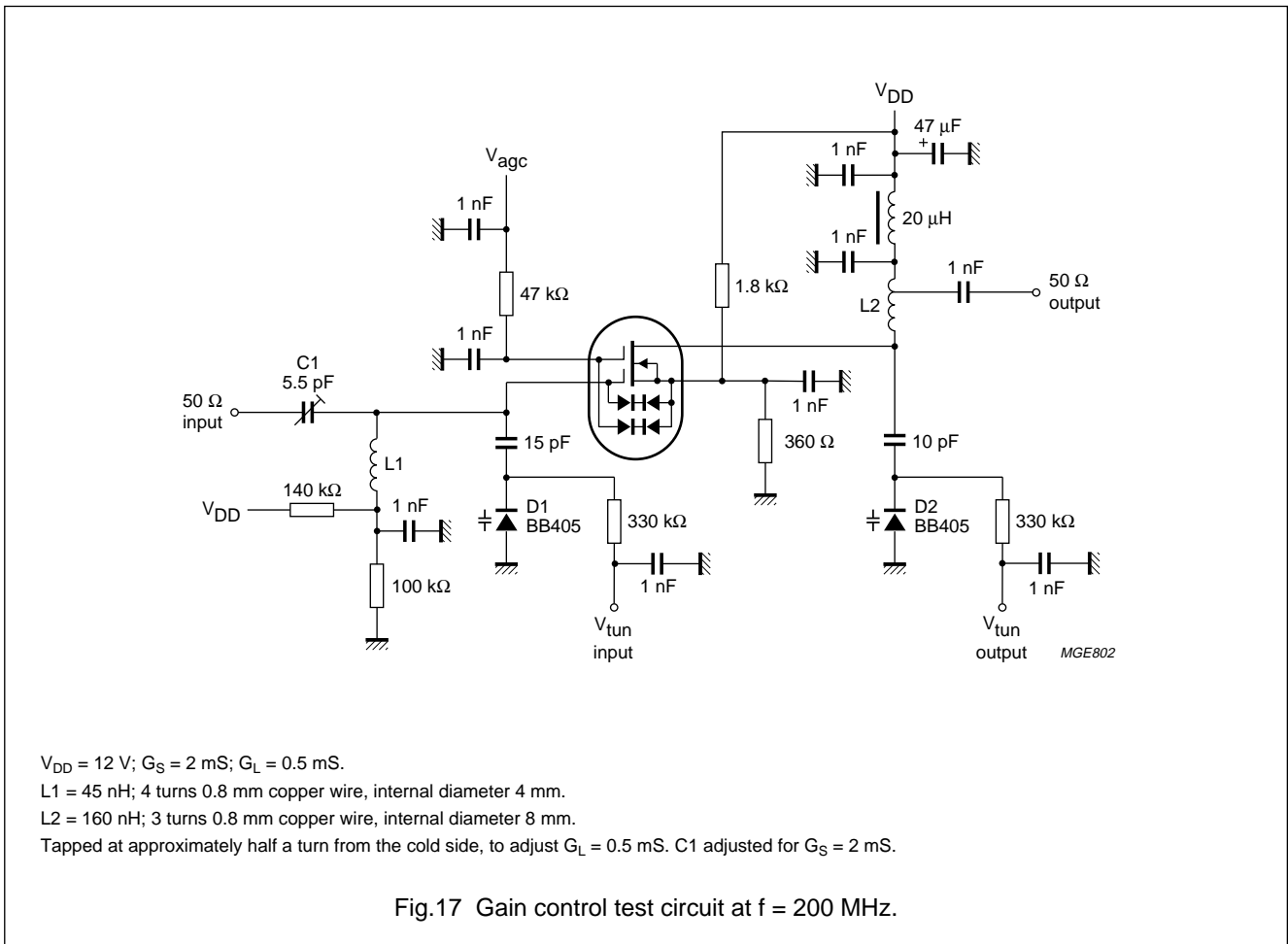
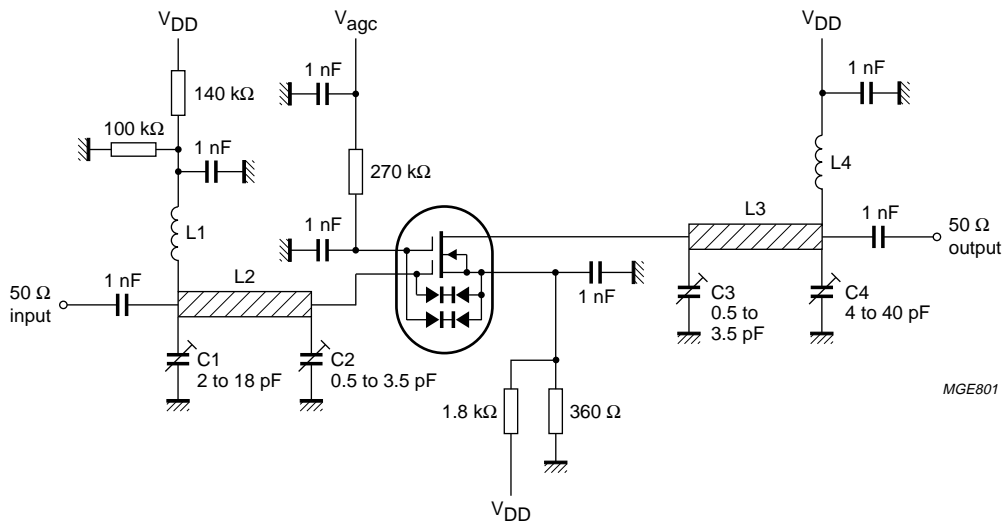


Fig.17 Gain control test circuit at $f = 200\text{ MHz}$.

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MGE801

$V_{DD} = 12\text{ V}$; $G_S = 3.3\text{ mS}$; $G_L = 1\text{ mS}$.

$L1 = L4 = 200\text{ nH}$; 11 turns 0.5 mm copper wire, without spacing, internal diameter 3 mm.

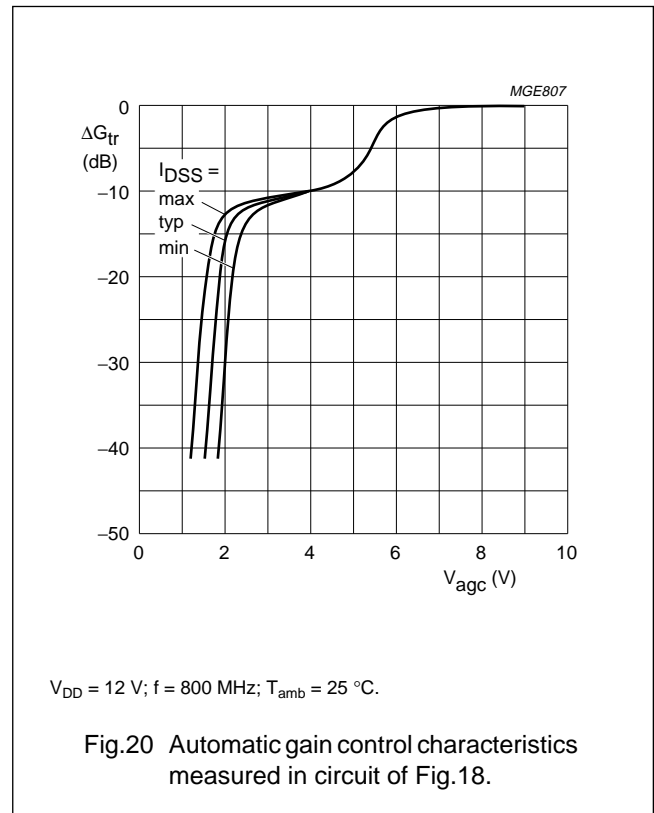
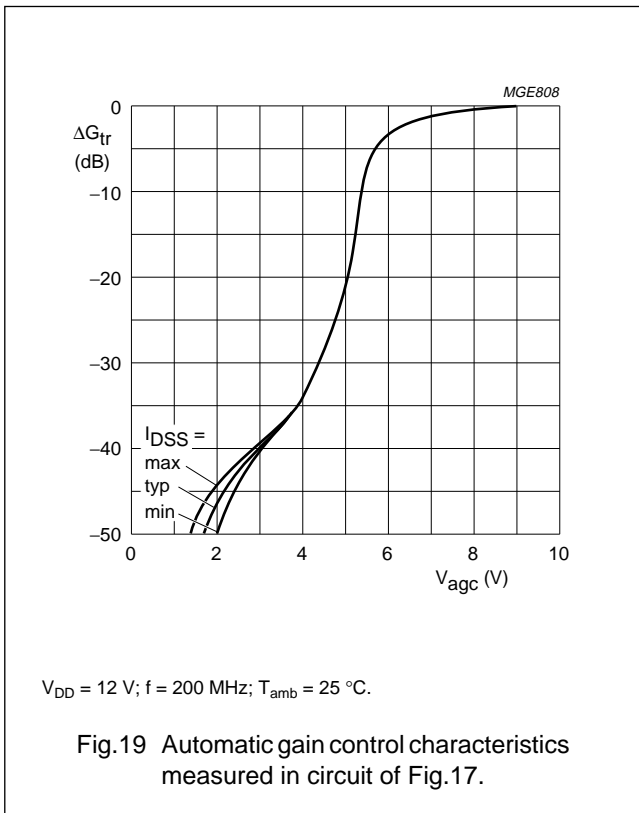
$L2 = 2\text{ cm}$, silvered 0.8 mm copper wire, 4 mm above ground plane.

$L3 = 2\text{ cm}$, silvered 0.5 mm copper wire, 4 mm above ground plane.

Fig.18 Gain control test circuit at $f = 800\text{ MHz}$.

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DEFINITIONS

| Data Sheet Status | |
|---|---|
| Objective specification | This data sheet contains target or goal specifications for product development. |
| Preliminary specification | This data sheet contains preliminary data; supplementary data may be published later. |
| Product specification | This data sheet contains final product specifications. |
| Limiting values | |
| Limiting values given are in accordance with the Absolute Maximum Rating System (IEC 134). Stress above one or more of the limiting values may cause permanent damage to the device. These are stress ratings only and operation of the device at these or at any other conditions above those given in the Characteristics sections of the specification is not implied. Exposure to limiting values for extended periods may affect device reliability. | |
| Application information | |
| Where application information is given, it is advisory and does not form part of the specification. | |

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